

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	1180	(216/41).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/15 15:13
S2	513	(216/58).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 14:07
S3	331	(216/77).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 14:13
S4	645	etch\$3 and aluminum and \$5resist and (MEA or monoethanolamine)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/15 15:15
S5	7	(etch\$3 and aluminum and \$5resist and (MEA or monoethanolamine)). clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 14:15
S6	7	("5202291" "5378653" "5399236" "5451293" "5468686" "5599743" "5700740").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/03/11 14:17
S7	305	etch\$3 and aluminum and \$5resist and (MEA or monoethanolamine) and (IPA or isopropyl)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 14:46
S8	213	etch\$3 and aluminum and \$5resist and (MEA or monoethanolamine) and (IPA or isopropyl) and (chlori\$2 or CL2 or "Cl.sub.2")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 14:54
S9	2816	etch\$3 and aluminum and \$5resist and passivation and (chlori\$2 or CL2 or "Cl.sub.2")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/14 16:10
S10	26	(etch\$3 and aluminum and \$5resist and passivation and (chlori\$2 or CL2 or "Cl.sub.2")).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 14:56

S11	2	S10 and (MEA or monoethanolamine)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 14:57
S12	1	S10 and (IPA or isopropyl)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 14:57
S13	370	(134/1.2).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:20
S14	842	(134/1.3).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:21
S15	2329	(134/2).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:21
S16	142	(216/57).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:21
S17	3722	(438/694).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:23
S18	366	(438/695).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:22
S19	168	S18 and aluminum	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:23
S20	106	S18 and aluminum and \$5resist	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:23

S21	4	S18 and (MEA or monoethanolamine)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:31
S22	393	(438/704).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:24
S23	1594	(438/706).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:24
S24	749	(438/720).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:26
S25	0	"method of stripping a photoresist"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:26
S26	740	((method or process) and (stripping adj2 photoresist)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:27
S27	24	S26 and aluminum and (MEA or monoethanolamine)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:29
S28	963	(430/329).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:28
S29	35	S28 and aluminum and (MEA or monoethanolamine)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/15 16:00
S30	50	S27 or S29	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:29

S31	17	(S27 or S29) and (Cl2 or chlori\$2 or "cl.sub.2")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:30
S32	48	(isopropyl or IPA) and (MEA or monoethanolamine) and passivation and remov\$3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/15 16:23
S33	18	(isopropyl or IPA) and (MEA or monoethanolamine) and passivation and stripping	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/11 15:37
S34	23	(etch\$3 and by-product and \$5resist)	DERWENT	OR	OFF	2005/03/14 16:10
S35	1433	etch\$3 same aluminum same \$5resist same (chlori\$2 or CL2 or "Cl.sub.2")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/14 16:14
S36	15	S35 and (MEA or monoethanolamine)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/14 16:12
S37	22428	strip\$3 with \$5resist	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/14 16:12
S38	301	S37 and (MEA or monoethanolamine)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/14 16:13
S39	279	S38 and (water or H2O or "H.sub.2O" or IPA or isopropyl)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/14 16:14
S40	160	S39 and (chlori\$2 or CL2 or "Cl.sub.2")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/14 16:14
S41	178	S39 and aluminum	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/14 16:14

S42	254	S39 and metal\$3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/14 16:15
S43	189	S39 and (plasma or ash\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/14 16:15
S44	402	(216/102).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/15 15:13
S45	2037	\$5resist and (MEA or monoethanolamine)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/15 16:07
S46	82	\$5resist and (MEA or monoethanolamine) and ((aluminum adj chloride) or "AlCl. sub.3" or "AlCl.sub.x" or AlCl3 or AlClx)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/15 15:18
S47	8	(("5202291") or ("5468686") or ("5451293") or ("5399236")).PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/15 16:01
S48	47140	(\$5resist).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/15 16:08
S49	439312	(\$5resist)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/15 16:09
S50	196682	(\$5resist and (remov\$3 or strip\$3 or wash\$3 or clean\$3) and (metal\$3 or copper or aluminum or titanium or nickel or cobalt or zirconium or iron or alloy or chromium or palladium or gold or silver))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/15 16:11
S51	812	(isopropyl or IPA) and (MEA or monoethanolamine) and \$5resist and remov\$3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/15 16:23

S52	7	((isopropyl or IPA) and (MEA or monoethanolamine) and \$5resist and (strip\$3 or remov\$3)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/15 16:23
S53	11	((isopropyl or IPA) same (MEA or monoethanolamine) same \$5resist same (strip\$3 or remov\$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/15 17:51